





### EDELWEISS-III progress report



The project Evolution of the scientific context Progress report Calendar, people and budget



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# THE EDELWEISS-III PROJECT

#### The EDELWEISS collaboration objectives

- Exploit the advantages of germanium cryogenic detectors for Direct Dark Matter searches
  - Germanium radiopurity
  - Superior energy resolution on both heat and ionization channels:
    - Distinct, event-by-event discrimination between nuclear electron recoils using ionization yield relative to heat signal
    - Low thresholds
    - Precise spectroscopy of any remaining backgrounds
- Obtain significant limits on WIMP with spin-independent interactions
- Develop a simple and robust detector unit that keeps all the advantages and can be adapted to larger scale project
  - Recognized expertise for heat-and-ionization detector design, fabrication and for understanding the physics of these device.

#### Germanium heat+ionization principle



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## Motivation for the EDELWEISS-III project (1)



#### Update since 2010:

- Publication of final exposure (384 kgd)
- Combination with CDMS (379 kgd), improves best limits by x1.5 at high mass: joint paper
- CDMS decides on an ID-inspired design for the electrodes of all its future detectors.

... as presented to the July 2010 IN2P3 Scientific Council

- With 10 x 400 g detectors (1.6 total fiducial mass) of the newly developped "ID" design, EDELWEISS improves x30 its previous background suppression performance and catches up with CDMS in terms of sensitivity
- First direct proof that "ID" electrode design can efficiently remove background from surface events



#### Surface event rejection with ID electrodes



region that needs it the most (surface)

#### Charge transport effects:

Diffusion (T=20mK) and charge repulsion removes problems that could have arisen from low-field regions

1.2 r (cm)

С

-1.0

1.0

#### Charge transport in cryogenic germanium



### **Reduction of backgrounds (1)**

Good understanding of the limiting backgrounds in EDELWEISS-II

Gamma-ray background (~1 bkg event in EDWII)

Compton with part in the guard region (low field + poor charge collection)

- Improve rejection with detector fully covered with interleaved electrodes
  - Reduction of non-fiducial volume from 60% to 20%
  - Better charge collection for surface events due to grid effect

#### Since 2010: rejection improvement observed in FID800 $\gamma$ calibrations



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### Reduction of backgrounds (2)

Good understanding of the limiting backgrounds in EDELWEISS-II

- Neutron background (~3 events in EDWII) alpha-n reaction in material inside polyethylene shield
  - better material selection
  - ~10 cm internal polyethylene shield



Surface events background (<0.2 events in EDWII)

- Material selection
- Improved ionization resolution



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## FIDSUSY proposal (2010)

- Science goal: have a Ge array able to get 3000 kgd (with <1 bkg event) in 6 months (=5x10<sup>-9</sup> pb)
- 40 x FID800 [ANR] can do this (... as early as 2012):
  - X4 fiducial mass/detector wrt EDWII ID
  - Surface rejection of ID already ok
  - Need to improve on the γ-rejection wrt EDWII: has been confirmed in 2011 Run15
  - Need x10 improvement in neutron rejection: **internal shield**
- Assumed 20 keV\_NR "sharp" threshold (reminder: EDW-II was 20 keV at the time)
  - Need improved/more reliable cabling, electronics (ionization resolutions >1 keV not acceptable) and cryogenics (main source of noise / deadtime due to excessive heat noise)

#### **EDELWEISS-III collaboration and tasks**



- Spokesman: *J. Gascon* (IPNL)
- Technical coordination: A. Juillard (IPNL)
- Relations with EURECA and CDMS: *G. Gerbier* (IRFU)

	Task	Coordinators		
/IRFU	Cryogenics	A. Benoit (Neel)		
RAMIS	Detectors	S. Marnieros (CSNSM), X.F. Navick (IRFU) A. Juillard (IPNL), H. Kraus (Oxford)		
IK IEK IPE	Cryogenic cabling			
	Electronics & DAQ	B. Paul + M. Gros (IRFU), M. Kleifges (IPE)		
UBNA	Low radioactivity and shielding	V. Kudryavtsev (Sheffield)		
	Muon veto and ancillary detectors	K. Eitel (IK), E. Yakushev (Dubna)		
ORD	<i>Offline and Monitoring</i>	E. Armengaud (IRFU), J. Gascon (IPNL)		
iv. FIELD /	<i>Database and documentation</i>	A. Cox + V. Kozlov (IK)		

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# **EVOLUTION OF THE SCIENTIFIC CONTEXT**

#### XENON-100 results

- 224 days
- 38 kg fiducial mass
- 2 observed events (predicted: 1)
- New limits: 2x10<sup>-9</sup> pb at M<sub>WIMP</sub>=50 GeV
- XENON 1t construction started
- 2400 kg Xe (XENON100 x 15)
- Data taking to start in 2015
- With x100 background reduction, goal of 2x10<sup>-11</sup> pb in 2017.





### SuperCDMS Soudan: 650g iZIPs

- Phonon timing + phonon symmetry + ID electrodes (but no veto electrode readout)
- 9 kg (6 kg fiducial)
- Data started in 2012, 2200 kgd by 2014 6x10<sup>-9</sup> pb for 100 GeV/c<sup>2</sup>
- Goals of low thresholds for low-mass WIMPs (at the expense of surface event rejection from phonon timing)



#### Future Project: SuperCDMS at SNOLAB

SuperCDMS Soudan SuperCDMS SNOLAB Double-sided Double-sided 2.5 cm thick 3.3 cm thick 3"diameter 4"diameter 7.5 cm 10 cm 620 g Ge 1.38 kg Ge 2 charge + 2 charge 2 charge + 2 charge 4 phonon + 4 phonon 6 phonon + 6 phonon Running 5 towers of 3 det each 24 towers of 6 det each Cushman, IDM2012 First prototypes

1.38 kg iZIPs

- R&D to be completed in 2013
- Goal: 200 kg Ge
  140 000 kgd
  (4 year run)
  10<sup>-10</sup> pb in ~2017

~EURECA time scale

#### **Recent EDELWEISS low mass analysis**

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- Realization that, despite being tuned for M<sub>WIMP</sub>~100 GeV, EDELWEISS-II had significant efficiency down to 5 keV recoil
- Significant background rejection with ID electrodes down to low energy: EDELWEISS-ID limit better than CDMS in 8-10 GeV range



 Resolutions are improving with new electronics (900 eV -> 650 eV for ionization, 1.25 -> <1 keV for heat)</li>

- 500 eV achieved in tests
  (HEMT R&D to go down to 300 eV?)
- EDW-III will have more aggressive goals concerning thresholds



 Coverage of low-mass region with 4 FID detectors with 300 eV FWHM resolutions (1200 kgd)



### **EDELWEISS-III Objectives Update**

- One year late (mainly: leakage current problem discussed later)
- Slope of 3000 kgd / 6 month should be reached mid-2013
- Achieved improvements in resolution show that an average 10 keV threshold is possible, with significant efficiency down and little backgrounds down to 5 keV
  - Improves sensitivity for 3000 kgd to 3-4x10<sup>-9</sup>pb instead of 5x10<sup>-9</sup>pb
  - 3 keV thresholds on a few R&D detectors is possible (HEMT)
- Range of background from internal neutrons limits total exposure to 4500 kgd (2.5x10<sup>-9</sup> pb at 15 keV) to 12000 kgd (10<sup>-9</sup> pb at 15 keV)
- Depending on backgrounds, EDELWEISS-III could reach 1 to 2.5x10<sup>-9</sup> pb before the start of XENON-1t and SuperCDMS SNOLAB
- Need to address low mass WIMPs
  - Recent paper: better than CDMS at 8-10 GeV/c<sup>2</sup>
  - ~5 keV threshold already possible with good IDs
  - significant surface event rejection with cut on veto signals



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# **PROGRESS REPORT**

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#### EDELWEISS electron-beam evaporator (CSNSM)

#### **FID detector processing**

- 810 g Ge crystals are received already polished & etched
  - 10 Canberra + 24 BSI received
  - Additional 10 BSI purchased
- α-Ge underlayer deposition
- Al electrodes & contact pads deposition
- Au heat link pads deposition
- Ion beam cleaning (Ar) prior to each deposition
- Mask positioning outside the evaporator
- Ge-NTD heat sensor gluing
- Process shortened to 2.5 day by using same mask for α-Ge and Al
- Planning based on 1 FID / week





Not readily available industrially



- Challenge wrt to ID: lateral evaporation
- First 3 FID800 could handle +-4V polarizations with no leakage current (<<1 fA)</li>
- Production of next 10 FIDs: all but the second one suffer from leakage between adjacent electrodes, on either curved or flat surfaces or both.
- Intensive study to understand the origin of this problem, and to find a solution
- One year delay in detector production

# Need a solution that keeps the simplicity of the process, is ~100% efficient and ideally can be used to repair detectors *after* the leakage diagnostic

- Several detector processing alternatives have been tested:
  - Electrodes under-layer material (H- $\alpha$ Ge,  $\alpha$ Ge, SiO, no under-layer)
  - Ion-beam cleaning optimization
  - Ammonium sulfide surface passivation
  - Chemical etching (selective etch of Ge relative to Au and Al) [CSNSM bolometer matrices R&D]
- After these studies and consulting experts (including CDMS, facing similar problems): problem most probably related to surface defects of Ge between Al electrodes, possibly linked to the initial mechanical polishing and chemical etching.

# The selected chemical etching procedure *after the detector fabrication* is 100% efficient in removing leakage currents problems (11/11 detector treated)

- A procedure has been optimized: it can be applied to the entire past production (without ungluing the NTD sensors) and preserves FID performances
- Actual procedure to be the object of a publication next year

## 2011-2012 calendar (1)

- 2011: Runs in Modane to help understand the leakage problems, and to study the performance of the three working FID800
  - Very good reproducibility
  - Fiducial volume conforms expectations
  - Improved gamma rejection than ID over entire fiducial volume
  - Better charge collection in non-fiducial regions than ID
- End 2011: Test new electronics, cabling and new NTD sensors
  - Baseline resolutions on fiducial ionization improves from ~1 keV (in EDELWEISS-II ID) to 0.65 keV FWHM
- Spring/Summer 2012: Upgrade of cryogenics
  - Lower and more consistent microphonics noise level to obtain a more homogeneous data sample with <1 keV heat resolution</li>

### New Cryogenics machines

- Objective: move "noisy" pulse-tube out of inner shields
- Replace with thermal machines on LSM wall
- Cold transported via fluids in caloduc



#### 2011-2012 calendar (2)

- Autumn 2012: Test of new Cu screens adapted to new PE shield
- Test of new kapton for 10-100 mK connection
- Preparation in IPNL of cabling for full detector array



Also at LSM: test of ZnMo detectors (A. Giuliani, ANR LUMINEU)



- Run 20 (started october 2012): 6 FIDs
  - Final confirmation of performance of detectors with new surface treatment (done)
  - High-statistics beta calibration of FID800
- Start now final production of FIDs (1/week)
- Installation of new cabling and shields in December
- Run with 15 FIDs starting January 2013
  - Commissioning, large-statistics gamma calibration
- Run with 40 in summer 2013
- First 3000 kgd in winter 2013 (3000 kgd per 6 months)
- >10 000 kgd before end 2015

# **PEOPLE AND BUDGET**

- We're within budget
- Savings on detector helped electronics + shields
- Investments spending 92% completed in 2012.

	2010 projection	Budget 2010-2013	2013 part	ANR part	in2p3 part
Detectors +NTDs	900 kE	810 kE	0	694 kE	0
Cryogenics	100 kE	138 kE	0	0	50
Electronics + cabling	330 kE	387 kE	110 kE	146 kE	30
Shields	30 kE	139 kE	0	0	0
Operations*	150 kE/y	112 kE/y	145 kE	0	~60 kE/y
4-year Total	2070 kE	1921 kE	255 kE	840 kE	330 kE

\* Costs of operations in LSM. Do not include travels (~40 kE/y for in2p3) and operations and R&D in in2p3 labs (~45 kE/y)

- More people than ever...
  - New group on DAQ electronics (IPE-Karlsruhe)
  - Excellent integration of recent members: IPE, and also Oxford (since 2010, cryogenic cabling) and Sheffield (since 2011, radioactive background and simulations)
  - 3 Postdocs (1 Paris, 2 KIT) + ...
  - 8 PhD (4.5 KIT, 1.5 Lyon, 1 Paris, 1 Oxford) + ...
  - 2 Diploma + ...
  - Since 2011, +2 permanents in IPNL, +1.5 in CSNSM, +1 in CEA, ...

- After a year delay solving leakage current problems, detector production can now resume
- The delay was used to progress on the upgrade of the environment (cryogenics, cabling, electronics, shielding)
  - New electronics and cryogenics have resulted in >30% improvements in resolutions with respect to EDELWEISS-II. The average threshold should move down from 20 to 10 keV, with significant efficiency down to 5 keV or less.
- The goal of 3000 kgd/ 6 month will be reached in 2013
- Background level estimates allow for a two year run, resulting in a sensitivity of >1x10<sup>-9</sup> pb
  - Establish our simple & reliable FID technology as the best starting point for future large-scale cryogenics Ge projects, in Europe or with American partners

#### **EDELWEISS FID detectors**



- EDW-II average FWHM keV: 0.9 Ion + 1.2 Heat
- (worse EDWII: 1.5 keV + 2 to 3 keV)



#### **CDMS ZIP detectors**

#### ZIP: Z-sensitive Ionization and Phonon Detector

#### Detectors :

- 250 g Ge or 100 g Si crystal
- 1 cm thick x 7.5 cm diameter
- Phonon Sensors : Superconducting W thermometer Photolithographic patterning

4 guadrants

- 37 cells per quadrant
- 6x4 array of 250µm x 1µm W TES per cell Each W sensor "fed" by 8 Al fins

#### - Ionization Sensors

2 electrodes (+ ground) allow rejection of events near outer edge

- Low impedance electronics with Squids
- + FETs pour lonisation







A. Reisetter, UMinn PRL 96,011302 (2006) Physics of phonons degradation : surface events have faster rise time.

 $\rightarrow$  2 parameters used for cuts :

- Primary risetime (delay 10% - 40% phonon amp.) Primary delay delay 20% charge amp and 20% phonon amp.) 46